Calculation of CC vs. fluence for different resistivities

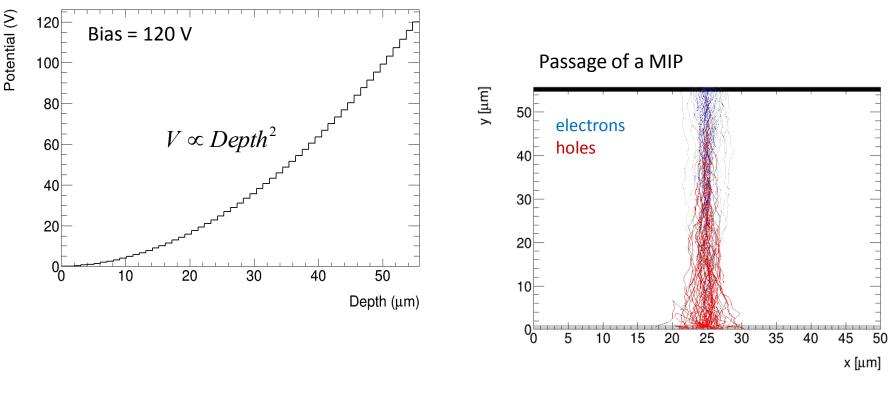
Assumptions:

1) planar (pad)detector geometry \rightarrow depleted depth: d

$$= \sqrt{\frac{2\mathcal{E}_0}{e_0 N_{eff}}} V_{bias}$$

- 2) detector thickness same as depleted depth → no influence of weighting field in irradiated detector
- 3) CC changes with fluence because of change of depleted depth (N_{eff}) and bacause of charge trapping

Use Gregor Kramberger's code: <u>http://www-f9.ijs.si/~gregor/KDetSim/</u> to calculate induced signals from MIP and estimate trapping loss



Potential in pad detector (example):

- buckets of charge treated as point charge

 calculate induced current of each bucket using Ramo's theorem Trapping:

$$\frac{1}{\tau_{eff}} = \beta \cdot \Phi_{eq}$$

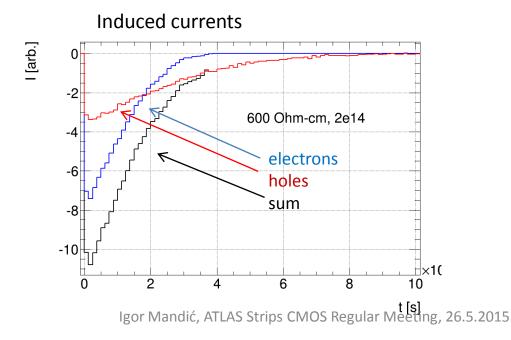
1

 $\beta = 4 \cdot 10^{-16} \text{ cm}^{-2} \text{ ns}^{-1}$ (for p-type silicon, V. Cindro et al., NIMA 599 (2009)60)

Induced current multiplied by: $I(t) = I_0(t) \cdot e^{-t/\tau_{eff}}$

Charge: integral of induced current

→compare charge before and after trapping to estimate the trapping loss at given detector thickness (depletion depth) and fluence



Evolution of N_{eff} with fluence:

HVCMOS (E-TCT measurements)

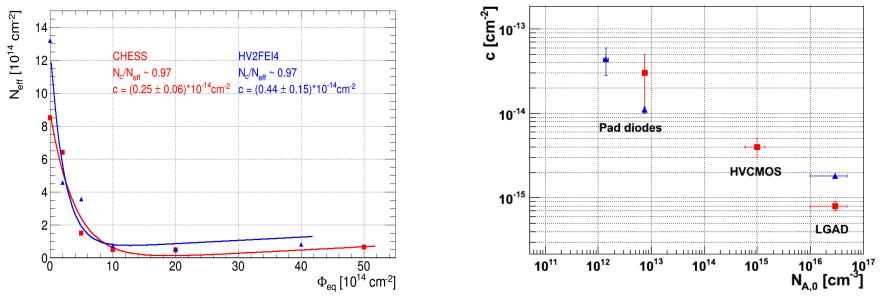
$$N_{eff} = N_{eff0} - N_c \cdot (1 - \exp(-c \cdot \Phi_{eq})) + g \cdot \Phi_{eq}$$

acceptor removal

Initial concentration

Radiation introduced deep acceptors (stable damage): $g \sim 0.02 \text{ cm}^{-1}$

Removal rate depends on initial space charge concentration



G. Kramberger, 10th Trento workshop

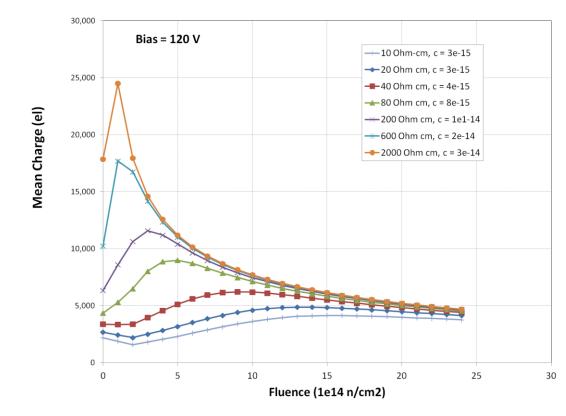
http://indico.cern.ch/event/351695/session/4/contribution/4/material/slides/0.pdf

Igor Mandić, ATLAS Strips CMOS Regular Meeting, 26.5.2015

Estimate CC for different resistivites:

1. calculate depletion depth from $N_{eff}(\Phi)$, bias = 120 V 2. calculate trapping loss at given depth and Φ

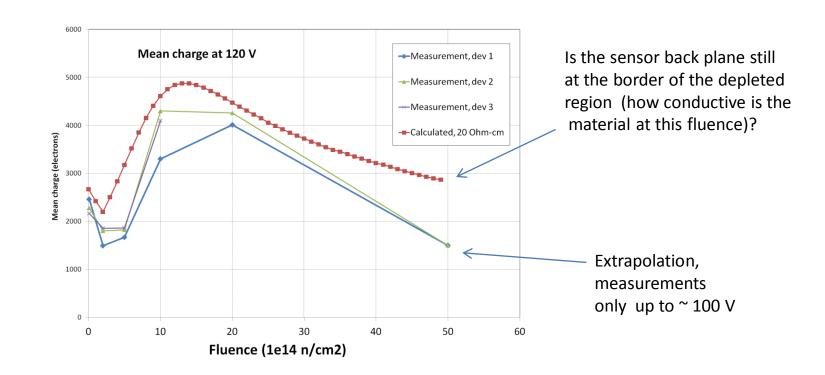
→ Mean Charge = depletion(µm)* 108 el/µm * trapping_loss + Mean Charge = depletion(µm)* 108 el/µm * trapping_loss + 0 el at $\Phi = 1e14$ \square 0 el at $\Phi > 1e14$ \square



Igor Mandić, ATLAS Strips CMOS Regular Meeting, 26.5.2015

Comparison with measurement

 \rightarrow agreement reasonable for this rough calculation



Conclusions:

Collected charge vs. fluence estimated for different detector resistivities:

- larger resistivity \rightarrow more charge
 - \rightarrow larger depletion \rightarrow initially smaller capacitance/noise
- at high fluence not much difference between materials
- for ~ 80 Ohm-cm charge not below initial up to 2e15
- → the selection of material resistivity depends on amplifier performance
 → how much charge is needed for good S/N